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Notice of Allowability	Application No.	Applicant(s)
	10/795,787	DEJIMA, YOSHIO
	Examiner	Art Unit
	Khanh B. Duong	2822
The MAILING DATE of this communication app All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85 NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT F of the Office or upon petition by the applicant. See 37 CFR 1.31	6 (OR REMAINS) CLOSED in to b) or other appropriate commun RIGHTS. This application is sul 3 and MPEP 1308.	his application. If not included ication will be mailed in due course. THIS
1. This communication is responsive to the amendment filed	<u>1 April 4, 2007</u> .	•
2. The allowed claim(s) is/are <u>4-10</u> .		
<ol> <li>Acknowledgment is made of a claim for foreign priority unally All b) ☐ Some* c) ☐ None of the:         <ol> <li>Certified copies of the priority documents have</li> <li>Certified copies of the priority documents have</li> <li>Copies of the certified copies of the priority documents have</li> <li>International Bureau (PCT Rule 17.2(a)).</li> </ol> </li> <li>* Certified copies not received:</li> </ol>	e been received. e been received in Application ocuments have been received i	No n this national stage application from the
Applicant has THREE MONTHS FROM THE "MAILING DATE" noted below. Failure to timely comply will result in ABANDONI THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.		reply complying with the requirements
<ol> <li>A SUBSTITUTE OATH OR DECLARATION must be subm INFORMAL PATENT APPLICATION (PTO-152) which given</li> </ol>		
5. CORRECTED DRAWINGS ( as "replacement sheets") mu	ist be submitted.	
(a) I including changes required by the Notice of Draftsper	son's Patent Drawing Review (	PTO-948) attached
1) 🗌 hereto or 2) 🔲 to Paper No./Mail Date	<u>.</u>	
(b) ☐ including changes required by the attached Examiner Paper No./Mail Date	's Amendment / Comment or in	the Office action of
Identifying indicia such as the application number (see 37 CFR each sheet. Replacement sheet(s) should be labeled as such in		
<ol> <li>DEPOSIT OF and/or INFORMATION about the deposit attached Examiner's comment regarding REQUIREMENT</li> </ol>	osit of BIOLOGICAL MATER FOR THE DEPOSIT OF BIOL	RIAL must be submitted. Note the OGICAL MATERIAL.
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Attachment(s)	<u> </u>	
1. Notice of References Cited (PTO-892)	<del></del>	rmal Patent Application
2. ☐ Notice of Draftperson's Patent Drawing Review (PTO-948)		nmary (PTO-413), ail Date
<ol> <li>Information Disclosure Statements (PTO/SB/08),</li> <li>Paper No./Mail Date</li> </ol>	7.   Examiner's A	mendment/Comment
<ol> <li>Examiner's Comment Regarding Requirement for Deposit of Biological Material</li> </ol>	9. ☐ Other	M. Wilczewski Primary Examiner
	-	TC2860

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## **DETAILED ACTION**

## Response to Amendment

This Office Action is in response to the amendment filed on April 4, 2007.

Accordingly, claims 1-3 were canceled. Claims 11-14 were previously canceled.

Currently, claims 4-10 are pending.

## Allowable Subject Matter

Claims 4-10 are allowed.

The following is an examiner's statement of reasons for allowance (as stated in the previous office action): none of the prior art of record, taken alone or in combination, fairly shows or suggests all the limitations as recited in the claims.

Re claim 4, none of the prior art of record discloses the following limitations in combination with the rest of the limitations in the claim: ashing the resist pattern until removal of the thin resist formed in the channel area is completed; and channel-etching the operation layer with the resist pattern which remains after the ashing.

Re claim 7, none of the prior art of record discloses the following limitations in combination with the rest of the limitations in the claim: ashing the resist pattern until removal of the thin resist formed in the pixel electrode formed area is completed; and etching the gate busline layer in the pixel electrode formed area with the resist pattern which remains after the ashing.

Re claim 10, none of the prior art of record discloses the following limitations in combination with the rest of the limitations in the claim: ashing the resist pattern until removal of the thin resist formed in areas other than the pixel electrode formed area is completed; and

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etching the transparent conductive film layer with the resist pattern which remains after the ashing.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

## Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Khanh B. Duong whose telephone number is (571) 272-1836. The examiner can normally be reached on 10:00-6:30.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Zandra Smith, can be reached on (571) 272-2429. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

VDD /

M. Wilczewski Primary Examiner TC 2800